

ABSTRACT OF THE DISCLOSURE

In an active matrix organic EL panel comprising a plurality of organic EL elements formed above a substrate, in 5 which each organic EL element includes at least an organic layer including an organic emissive material between a lower individual electrode which is individually patterned for each pixel and an upper electrode, an edge covering insulating layer is formed covering peripheral end portions of the lower 10 individual electrode, and a mask supporting insulating layer having a thickness greater than the edge covering insulating layer for supporting a deposition mask used for formation of the organic layer is formed on the outer peripheral region with respect to the edge covering insulating layer. The organic 15 layer extends to the outer region with respect to the boundary between the edge covering insulating layer and the lower individual electrode and terminates on the inner region with respect to a region where the mask supporting insulating layer is formed. The organic layer is individually patterned for 20 each pixel. Damage of the organic layer or generation of dust, both cause by contacting the organic layer and the mask when the mask is aligned while supported by the mask supporting insulating layer can be prevented.